



# INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

Document Number (Optional)

MSLIN 98-002555TP  
- CIPB

Application Number

10/783,195

Applicant

M.S. Lin et al.

Filing Date

02/20/04

Drawn At Unit

## U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	PUB. DATE IF APPROPRIATE
TLI	6229221	5/8/01	Kloen et al.	257	784	12/6/99
	5719448	2/17/98	Ichikawa	257	781	10/26/93
	6710460	3/23/04	Morozumi	257	779	6/3/02
	5384488	1/24/95	Golshan et al.	257	786	10/3/93
	6800555	10/5/04	Test et al.	438	687	3/23/01
	6459135	10/1/02	Basteres et al.	257	528	3/15/00
	6544880	4/8/03	Akram	438	617	6/14/99
	5789303	8/4/98	Leung et al.	438	381	7/11/96
	6184143	2/6/01	Ohashi et al.	438	697	7/28/98
	5659201	8/19/97	Wollesen	257	758	6/5/95
	6187680	2/13/01	Costrini et al.	438	688	10/7/98

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

TLI	U.S. Patent App. Pub. US 2002/0158334 A1 to Vu et al., U.S. Cl. 257/723, Pub. Date 10/31/02, Filed 4/30/01.
TLI	U.S. Patent App. Pub. US 2001/0035452 A1 to Test et al., U.S. Cl. 228/180.5, Pub. Date 11/1/01, Filed 3/23/01

EXAMINER

/Thao Le/

DATE CONSIDERED

03/10/2007

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

Form PTO-1449

INFORMATION DISCLOSURE CITATION  
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Document Number (Optional)

MSLIN 98-002 CCC IP  
-CTPB

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M.S. Lin et al.

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Group Art Unit

## U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	PRIOR DATE & APPROXIMATE
TLI	5969424	10/19/99	Matsuki et al.	257	768	12/29/97
	6272736	8/14/01	Lee	29	620	11/13/98
	6383916	5/7/02	Lin	438	637	2/17/99
	6649509	11/18/03	Lin et al.	438	618	10/24/01
	6756295	6/29/04	Lin et al.	438	612	4/15/02
	6593649	7/15/03	Lin et al.	257	697	5/17/01
	6495442	12/17/02	Lin et al.	438	618	10/18/00
	6455885	9/24/02	Lin	257	300	10/8/01
	6103552	8/15/00	Lin	438	113	8/10/98
↓	6350705	2/26/02	Lin	438	779	7/14/00
	5468984	11/21/95	Efland et al.	257	356	11/2/94

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